

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application of:	Toshihiko OHASHI et al.		
Application No.:	10/541,776	Confirmation No.:	1474
Filed:	July 08, 2005	Art Unit:	1794
For:	SILICA-CONTAINING LAMINATED STRUCTURE, AND COATING COMPOSITION FOR USE IN FORMING A POROUS SILICA LAYER	Examiner:	V. CHANG

AMENDMENT UNDER 37 C.F.R. § 1.116

DO NOT ENTER: /N.C./

MS AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

INTRODUCTORY COMMENTS

In reply to the Office Action dated July 30, 2010, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

Amendments to the Claims begin on page 2.

Remarks begin on page 8.

Attachments: Exhibits 1-3